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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Daniel Alvarez, Jr. and Jeffrey J. Spiegelman

Application No.: 10/692,018 Group: 1724

Filed: October 23, 2003 Examiner: Frank M. Lawrence, Jr.

Confirmation No.: 8519

For: METHOD FOR PURIFICATION OF LENS GASES USED IN
PHOTOLITHOGRAPHY

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AMENDMENT AFTER FINAL REJECTION UNDER 37 C.F.R. § 1.116

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Sir:

This Amendment After Final Rejection is being filed in response to the Final Office Action mailed from the U.S. Patent and Trademark Office on April 1, 2005 in the above-identified application. Reconsideration and further examination are requested.

Please amend the application as follows: